

APPLICANTS: Choi et al.  
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FOR: PROCESS FOR FORMING ELECTRODES

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formed from a conductive transparent metal-oxide. The electrode regions are spaced apart and deposited on a base coating with a protective dielectric layer covering the electrode regions and spaces. Austin does not show or suggest a high index top layer having a conductivity ranging from about 100 ohms/square to about 400 ohms/square formed on the conductive layer with at least the top layer and the conductive layer being patterned so as to divide the conductive layer into a plurality of discrete electrodes.

Dependent claims 19-28 depend directly from independent claim 18 and thus contain all of the limitations of the independent claim from which they depend. Therefore, these dependent claims are patentable over Yatabe et al. and Austin either alone or in combination, for at least the same reasons set forth above with respect to claim 18.

Enclosed is a Petition for a Two Month Extension of Time. Please charge the required fee to Deposit Account No. 50-1721.

Applicants submit that all of the claims are now in condition for allowance, which action is requested. Please apply any charges or credits to Deposit Account No. 50-1721.

Respectfully submitted,



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